

Supplementary Materials

Design and performance of novel self-cleaning g-C₃N₄/PMMA/PUR membrane

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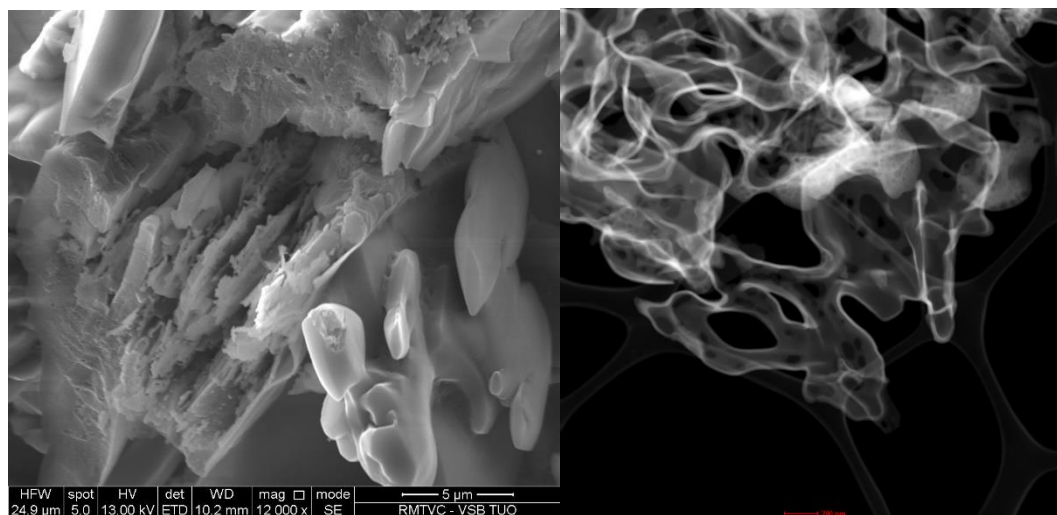


Figure S1 SEM images of bulk g-C₃N₄ (left) and STEM image of detailed thin structure of ECN (right).

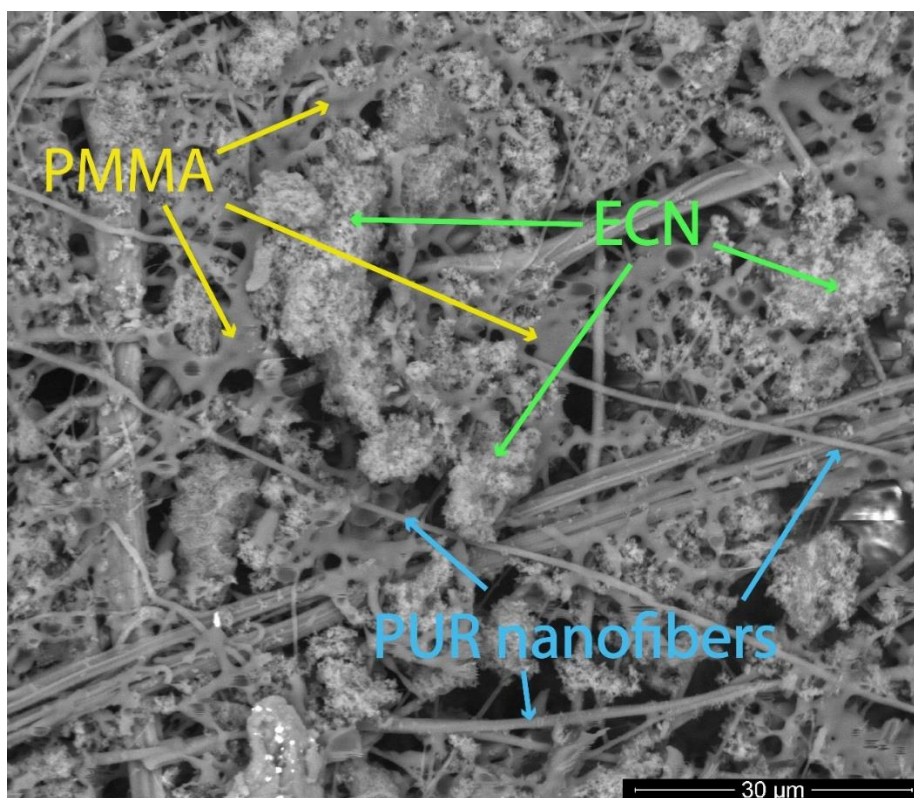


Figure S2 HRSEM image of modified S4 fabric with indication of materials.

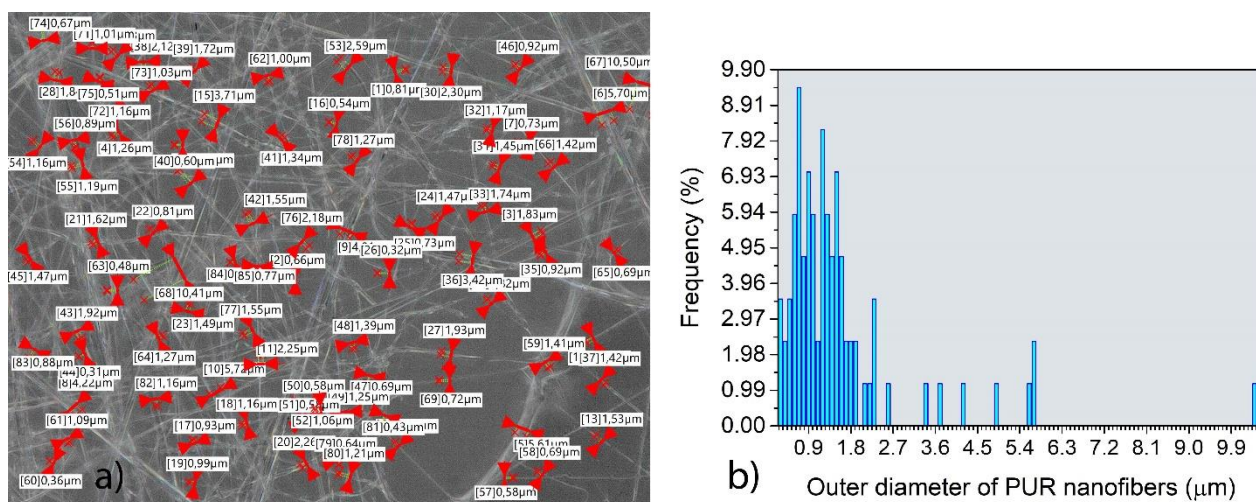


Figure S3. a) Microscope image with measured outer diameter of PUR nanofibers, b) outer diameter histogram.

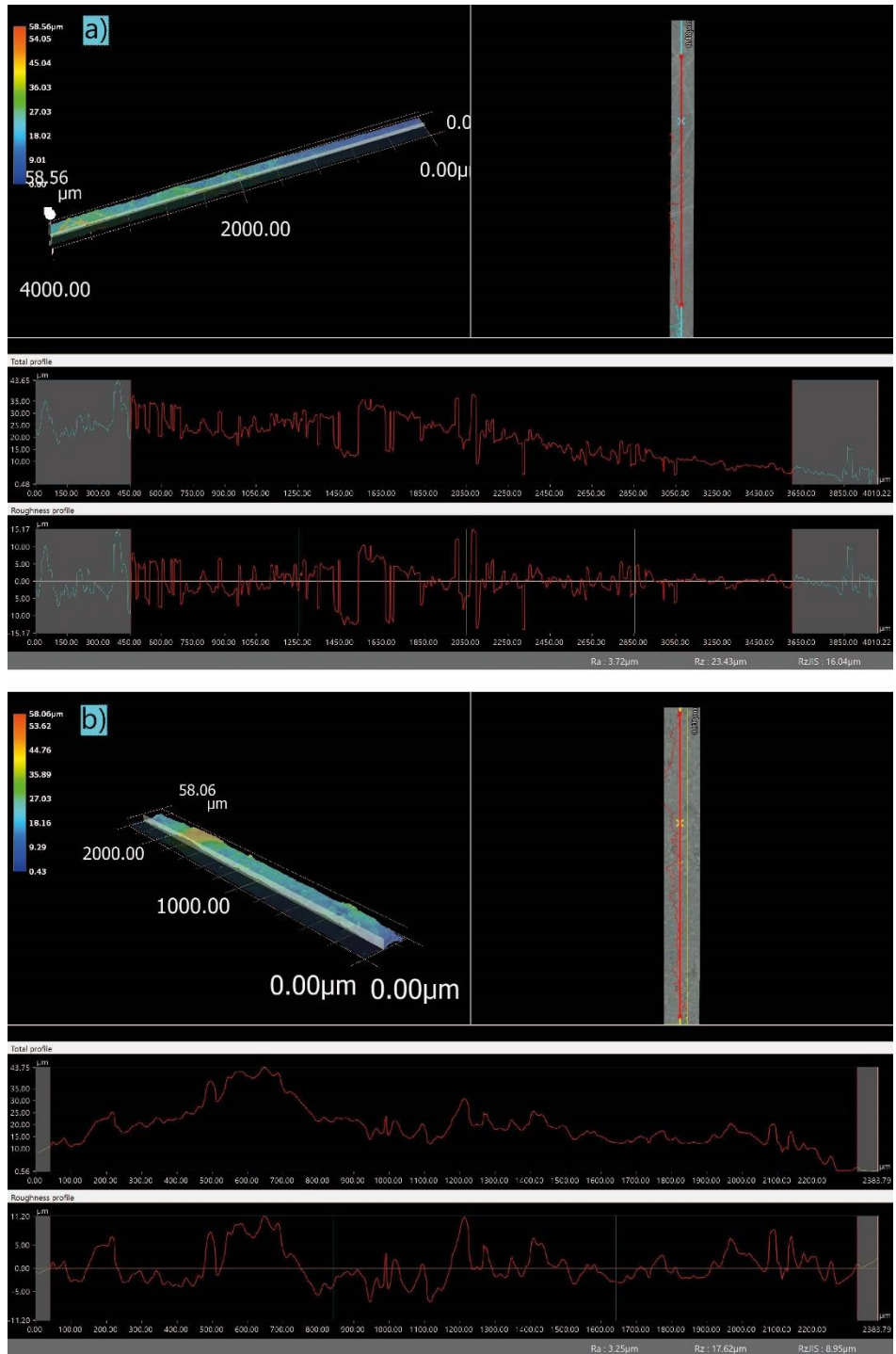


Figure S4. Images of roughness measurement performed on a) unmodified fabric and b) modified S4 fabric.